IN THE CLAIMS

Claims 1-17: Canceled.

18. (Currently Amended) A planarization composition, [[comprising]] consisting essentially of:

an o-cresol-based polymer compound and a resol phenolic resin;

at least one surfactant; and

a solvent system comprising at least one alcohol and at least one ether acetate-based solvent.

19. (Currently Amended) The planarization composition of claim 18, wherein the o-cresol-based polymer compound comprises a novolac polymer.

20. (Original) The planarization composition of claim 18, wherein the at least one alcohol comprises a branched alcohol.

21. (Original) The planarization composition of claim 20, wherein the branched alcohol comprises 2-propanol.

22. (Currently Amended) The planarization composition of claim 18, wherein the at least one ether acetate-based solvent comprises propylene glycol methylether acetate (PGMEA) [[PGMEA]].

23. Canceled.

24. (Previously Presented) The planarization composition of claim 18, wherein the surfactant comprises at least one hydrocarbon surfactant, at least one fluorocarbon surfactant or a combination thereof.

25. (Previously Presented) The planarization composition of claim 24, wherein the at least one fluorocarbon surfactant comprises at least one fluoroaliphatic polymeric ester surfactant.

26. (Previously Presented) A film comprising the planarization composition of claim 18, wherein at least some of the solvent system is removed.

27. (Currently Amended) A film comprising the planarization composition of claim [[23]] 24, wherein at least some of the solvent system is removed.

Claims 28-29: Canceled.

30. (Original) A layered component, comprising:

a substrate having a surface topography; and

a planarization composition of claim 18, wherein the composition is coupled to the substrate.

31. (Original) The layered component of claim 30, further comprising at least one additional layer of material or film.

32. (Original) A layered component, comprising:

a substrate having a surface topography; and

a layer comprising the film of claim 26, wherein the layer is coupled to the substrate.

33. (Original) The layered component of claim 32, further comprising at least one additional layer of material or film.

34. (Original) A layered component, comprising:

a substrate having a surface topography; and

a layer comprising the film of claim 27, wherein the layer is coupled to the substrate.

35. (Original) The layered component of claim 34, further comprising at least one additional layer of material or film.

36. (Currently Amended) A method of forming a planarization composition, [[comprising]] consisting essentially of:

providing a structural constituent, wherein the structural constituent comprises an o-cresol-based polymer compound and a resol phenolic resin;

providing at least one surfactant;

providing a solvent system, wherein the solvent system comprises at least one alcohol and at least one ether acetate-based solvent; and

blending the structural constituent, the at least one surfactant and the solvent system to form a planarization composition.

Claims 37-38: Canceled.

39. (Currently Amended) The method of claim 36, wherein the solvent system comprises at least [[two]] three solvents.

40. (Original) The method of claim 39, wherein the solvent system comprises an alcohol-based solvent.

41. (Previously Presented) The method of claim 40, wherein the alcohol-based solvent comprises 1-propanol or 2-propanol.

42. (Previously Presented) The method of claim 39, wherein the solvent system comprises propylene glycol methylether acetate (PGMEA), ethyl lactate, propylene glycol methyl ether, diethylene glycol, 2-propanol, acetone or a combination thereof.

43. (Original) The method of claim 36, wherein the intermolecular forces component comprises hydrogen bonding interactions, electrostatic forces, steric forces, dipole-dipole interactions, dispersion forces, Van der Waals forces or combinations thereof.

44. (Original) The method of claim 36, wherein the surface forces component comprises an interfacial surface tension.

45. (Previously Presented) The method of claim 44, wherein the solvent system lowers the interfacial surface tension by at least 10%.

46. (Previously Presented) The method of claim 45, wherein the solvent system lowers the interfacial surface tension by at least 20%.

47. (Original) The method of claim 36, wherein the planarization composition comprises an apparent viscosity.

48. (Previously Presented) The method of claim 47, wherein the solvent system lowers the apparent viscosity by at least 10%.

49. (Original) The method of claim 48, wherein the solvent system lowers the apparent viscosity by at least 30%.

50. Canceled.

51. (Previously Presented) The method of claim 36, wherein the surfactant comprises at least one hydrocarbon surfactant, at least one fluorocarbon surfactant or a combination thereof.

52. (Previously Presented) The method of claim 51, wherein the at least one fluorocarbon surfactant comprises at least one fluoroaliphatic polymeric ester surfactant.

53. (Previously Presented) A method of forming a film, comprising:

providing the planarization composition of claim 18; and

evaporating at least part of the solvent system to form a film.

54. (Original) The method of claim 53, wherein evaporating at least part of the solvent system comprises applying a continuous source to the planarization composition.

55. (Original) The method of claim 54, wherein the continuous source comprises a heat source.

56. (Original) The method of claim 55, wherein the continuous source comprises an infrared source, an ultraviolet source, an electron-beam source and combinations thereof.

Claims 57-75: Canceled.